



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: De et al.

Serial No. 10/699,298

Title: NOVEL COPOLYMER, PHOTORESIST COMPOSITIONS THEREOF  
AND DEEP UV BILAYER SYSTEM THEREOF

Filed: October 31, 2003

Examiner: Christopher M. Keehan

Art Unit: 1712

Confirmation No.: 5394

Customer No. : 27,623

Attorney Docket No.: 335.7735USU

Mail Stop: AMENDMENT  
Commissioner For Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE TO OFFICE ACTION OF SEPT. 27, 2004**

Honorable Commissioner for Patents:

The amended claims in this application are as set forth in the next section of this Response.  
The claims are allowable for the reasons set forth in the Remarks section of this Response.